

GEMOLOGICAL INSTITUTE

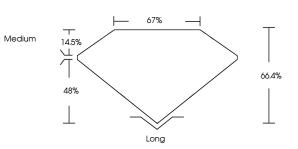
# **ELECTRONIC COPY**

## LABORATORY GROWN DIAMOND REPORT

October 28, 2024				
IGI Report Number	LG662451994			
Description	LABORATORY GROWN DIAMOND			
Shape and Cutting Style	EMERALD CUT			
Measurements	11.25 X 7.54 X 5.01 MM			
GRADING RESULTS				
Carat Weight	4.42 CARATS			
Color Grade	D			
Clarity Grade	VVS 2			
ADDITIONAL GRADING INFORMATION				
Polish	EXCELLENT			

Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	NONE
Inscription(s)	(G) LG662451994

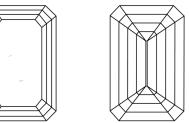
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa



LG662451994

Report verification at igi.org

### **CLARITY CHARACTERISTICS**



#### **KEY TO SYMBOLS**

Red symbols indicate internal characteristics. Green symbols indicate external characteristics.

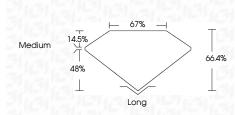
151 LG662451994 Sample Image Used

## COLOR

D E F	GHIJ	Faint	Very Light	Light
CLARITY	WS <sup>1-2</sup>	VS <sup>1-2</sup>	SI <sup>1-2</sup>	1-3
Internally Flawless	Very Very Slightly Included	Very Slightly Included	Slightly Included	Included

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#### ADDITIONAL GRADING INFORMATION

Polish EXCELLENT   Symmetry EXCELLENT   Fluorescence NONE   Inscription(s) Image Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.   Type IIa		
Fluorescence NONE Inscription(s) (G) LG662451994 Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.	Polish	EXCELLENT
Inscription(s) (GC LG662451994 Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.	Symmetry	EXCELLENT
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.	Fluorescence	NONE
created by Chemical Vapor Deposition (CVD) growth process.	Inscription(s)	(137) LG662451994
	created by Chemical Vapo process.	





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